Proximity Glare Suppression for Astronomical Coronagraphy

This subtopic section addresses the unique problem of imaging and spectroscopic characterization of faint astrophysical objects that are located within the obscuring glare of much brighter stellar sources and innovative advanced wavefront sensing and control for cost-effective space telescopes. Examples include: planetary systems beyond our own, the detailed inner structure of galaxies with very bright nuclei, binary star formation, and stellar evolution. Contrast ratios of one million to ten billion over an angular spatial scale of 0.05-1.5 arcsec are typical of these objects. Achieving a very low background requires control of both scattered and diffracted light. The failure to control either amplitude or phase fluctuations in the optical train severely reduces the effectiveness of starlight cancellation schemes.

This innovative research focuses on advances in coronagraphic instruments, starlight cancellation instruments, and potential occulting technologies that operate at visible and infrared wavelengths. The ultimate application of these instruments is to operate in space as part of a future observatory mission. Much of the scientific instrumentation used in future NASA observatories for the astrophysical sciences will require control of unwanted radiation (thermal and scattered) across a modest field of view. The performance and observing efficiency of astrophysics instruments, however, must be greatly enhanced. The instrument components are expected to offer much higher optical throughput, larger fields of view, and better detector performance. The wavelengths of primary interest extend from the visible to the thermal infrared. Measurement techniques include imaging, photometry, spectroscopy, and polarimetry. There is interest in component development, and innovative instrument design, as well as in the fabrication of subsystem devices to include, but are not limited to, the following areas:

- Advanced starlight canceling coronagraphic instrument concepts;
- Advanced aperture apodization and aperture shaping techniques;
• Pupil plane masks for interferometry;

• Advanced apodization mask or occulting spot fabrication technology controlling smooth density gradients to 10^{-4} with spatial resolutions ~1 \mu m, low dispersion, and low dependence of phase on optical density;

• Metrology for detailed evaluation of compact, deep density apodizing masks, Lyot stops, and other types of graded and binary mask elements. Development of a system to measure spatial optical density, phase inhomogeneity, scattering, spectral dispersion, thermal variations, and to otherwise estimate the accuracy of masks and stops is needed;

• Interferometric starlight cancellation instruments and techniques to include aperture synthesis and single input beam combination strategies;

• Single mode fiber filtering from visible to 20 \mu m wavelength;

• Methods of polarization control and polarization apodization; and

• Components and methods to insure amplitude uniformity in both coronagraphs and interferometers, specifically materials, processes, and metrology to insure coating uniformity.

Wavefront Control Technologies

• Development of small stroke, high precision, deformable mirrors (DM) and associated driving electronics scalable to 10^4 or more actuators (both to further the state-of-the-art towards flight-like hardware and to explore novel concepts). Multiple DM technologies in various phases of development and processes are encouraged to ultimately improve the state-of-the-art in deformable mirror technology. Process improvements are needed to improve repeatability, yield, and performance precision of current devices;

• Development of instruments to perform broad-band sensing of wavefronts and distinguish amplitude and phase in the wavefront.

• Adaptive optics actuators, integrated mirror/actuator programmable deformable mirror;

• Reliability and qualification of actuators and structures in deformable mirrors to eliminate or mitigate single actuator failures;

• Multiplexer development for electrical connection to deformable mirrors that has ultra-low power dissipation.

• High precision wavefront error sensing and control techniques to improve and advance coronagraphic imaging performance; and

• Highly reflecting broadband coatings.

Precision Deployable Optical Structures and Metrology

Planned future NASA Missions in astrophysics, (such as the Single Aperture Far-IR (SAFIR) telescope, Life Finder, and Submillimeter Probe of the Evolution of Cosmic Structure (SPECS), and the UV Optical Imager (UVOIR) require 10 - 30 m class cost effective telescopes that are diffraction limited at wavelengths from the visible to the far IR, and operate at temperatures from 4 - 300 K. The desired areal density is 1 - 10 kg/m^2. Static and dynamic wavefront error tolerances may be achieved through passive means (e.g., via a high stiffness system) or through active control. Potential architecture implementations must package into an existing launch volume, deploy and be self-aligning to the micron level. The target space environment is expected to be L2.
This subtopic section solicits proposals to develop enabling, cost effective component and subsystem technology for these telescopes. Research areas of particular interest include: precision deployable structures and metrology, i.e., innovative active or passive deployable primary or secondary support structures; innovative concepts for packaging fully integrated (i.e., including power distribution, sensing, and control components), distributed and localized actuation systems; deployment packaging and mechanisms; active control distributed on or within the structure (downstream corrective and adaptive optics are not included in this topic area); actuator systems for alignment of reflector panels (order of cm stroke actuators, lightweight, submicron dynamic range, nanometer stability); mechanical, inflatable, or other deployable technologies; new thermally-stable materials (CTE)

Also of interest are innovative metrology systems for direct measurement of the optical elements or their supporting structure. Requirements for micron level absolute and subnanometer relative metrology for tens of points on the primary mirror. Also measurement of the metering truss. Innovative systems which minimize complexity, mass, power and cost are sought.

The goal for this effort is to mature technologies that can be used to fabricate 20 m class, lightweight, ambient or cryogenic flight-qualified telescope primary mirror systems. Proposals to fabricate demonstration components and subsystems with direct scalability to flight systems (concept described in the proposal) will be given preference. The target launch volume and expected disturbances, along with the estimate of system performance, should be included in the discussion. A successful proposal shows a path toward a Phase 2 delivery of demonstration hardware on the scale of 3 m for characterization.